Concurrent thermal conductivity measurement and internal structure observation of individual one-dimensional materials using scanning transmission electron microscopy

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3	scanning transmission electron microscopy
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7 8 9	² International Institute for Carbon-Neutral Energy Research (WPI-I2CNER), Kyushu University, 744 Motooka, Fukuoka 819-0395, Japan Abstract
10	The thermal conductivity of individual nanomaterials can vary from sample to sample due to the
11	difference in the geometries and internal structures and thus concurrent structure observation and
12	thermal conductivity measurement at the nanoscale is highly desired but challenging. Here we have
13	developed an experimental method that allows concurrently the <i>in-situ</i> thermal conductivity
14	measurement and the real-time internal structure observation of a single one-dimensional (1D) material
15	using scanning transmission electron microscopy in a scanning electron microscope (STEM-in-SEM).
16	In this method, the two ends of the 1D nanomaterial are bonded on a tungsten probe and a suspended
17	platinum nanofilm, respectively. The platinum nanofilm serves simultaneously as a heater and a
18	resistance thermometer, ensuring highly sensitive thermal measurements. The platinum nanofilm is
19	fabricated on the edge of the silicon wafer so that the electron beam can transmit through the 1D material
20	and be detected by the STEM detector, which caters for real-time observation of the inner nanostructure.
21	Using this method, we in-situ measured the thermal conductivities of two cup-stacked carbon nanotubes
22	and concurrently observed the internal hollow structures. We found that the sample with more structural
23	disorders had a lower thermal conductivity. Our measurement method can pave the way to the sample-
24	by-sample elucidation of the structure-property relationship for 1D materials.
25	
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27 Main Text

The relationship between the nanomaterial structure and its thermophysical properties keeps a 28 29 captivating subject of both fundamental and applied interest since it can not only uncover the nanoscale 30 heat transfer mechanisms but also guide the modulation of the material performance for wide applications including thermal management and thermoelectrics.^{1.4} Several experimental methods have 31 been exploited and applied to measure the thermophysical properties of nanomaterials and reveal the 32 microscopic heat transfer mechanisms, represented by the microbridge device method,⁵⁻⁸ T-type 33 method,⁹⁻¹² Raman optothermal method,¹³⁻²³ electrical self-heating method,²⁴⁻²⁶ and so forth. However, 34 35 these measurement methods cannot capture the real-time internal structure details of the nanomaterial 36 sample during thermal measurement. Especially for nanowires and nanotubes, usually, the internal structure of the sample is characterized using transmission electron microscopy (TEM) before the 37 38 thermal measurement. However, the nanomaterial samples from the same batch, and even the different 39 parts of the same individual sample, can often exhibit structural differences, so the separate structural 40 characterization cannot clarify the property-structure relationship. Hence, it is desperately desired to 41 observe the internal structures along with the thermal measurement to gain insight into the relationship between the structure and the thermophysical properties. 42

In-situ TEM with atomic imaging resolution is a powerful technique to study the structure-property 43 relationship in real time.^{27, 28} A series of exciting and impressive efforts have been conducted, however, 44 these endeavors mainly focus on the in-situ electrical properties measurement in TEM.²⁹⁻³¹ A few in-45 situ thermal measurements in TEM include the qualitative observation of anisotropic thermal transport 46 47 in a CNT bundle by monitoring the phase change of gold nanoparticles as thermo-markers,³² and the nanoscale temperature detection with a well-designed nano-thermocouple assembled in TEM.33 48 49 However, these methods are not suitable for the quantitative thermal conductivity measurement of 50 individual nanomaterials. In 2007, a hot-wire thermal probe for the *in-situ* thermal conductivity measurement of 1D materials in TEM was reported,³⁴ but the complicated fabrication of the hot-wire 51

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52 probe, the TEM-related assembly, and the difficult TEM operations have so far brought many challenges53 in the application of this method.

54 In the present work, we develop an experimental method that facilitates *in-situ* thermal 55 conductivity measurement and internal structure observation of individual 1D materials using scanning 56 transmission electron microscopy in a scanning electron microscope that incorporates the STEM detector into the standard SEM.³⁵ Despite lower spatial resolution than TEM, STEM-in-SEM is much 57 58 easier to operate than TEM, and has a much lower accelerating voltage for the electron beam (EB) that 59 can avoid possible damage on the nanomaterial. We applied this method in the *in-situ* thermal conductivity measurement of cup-stacked carbon nanotubes (CNTs), the results of which validated our 60 in-situ measurement method. The cup-stacked CNTs have a relatively complicated structure,³⁶ and the 61 thermal conductivity can depend more significantly on the structure than normal multiwalled CNTs. We 62 63 observed the internal hollow structure of the cup-stacked CNTs in real time while measuring the thermal conductivity in situ. Our method offers a powerful tool to explore the real-time influence of structures, 64 65 encapsulation, infusion, deformation, and so forth, on the thermophysical properties.

66 Figure 1 delineates the schematic diagram of the *in-situ* and real-time thermal conductivity measurement. The two ends of a 1D sample are bonded on a tungsten manipulator probe and a 67 68 suspended platinum nanofilm by electron-beam induced deposition (EBID), respectively. The in-situ thermal conductivity measurement is evolved from the T-type method^{9, 10, 34} by comparing the 69 70 temperature rise of the nanofilm caused by the Joule heating before and after the 1D sample transfer, 71 where the probe equates with the heat sink and the Pt nanofilm serves simultaneously as a heater and a 72 resistance thermometer. Since the calibration of nanofilm properties and our in-situ and real-time 73 thermal characterizations are conducted under the high vacuum conditions inside the SEM chamber and 74 the temperature rise is controlled small enough, the effects of both radiation and convection are 75 negligible. The total thermal resistance ($R_{t,tot}$), which includes the thermal resistance of the 1D sample 76 $(l_{1D}/\lambda_{1D}A_{1D})$ and the thermal contact resistance $(R_{t,c})$ between the sensor and the sample, can be extracted



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 $R_{\rm t,tot} = \frac{l_{\rm 1D}}{\lambda_{\rm 1D}A_{\rm 1D}} + R_{\rm t,c} = \frac{3\left(\frac{dR_0}{dT_0}\right)l_{\rm s}^2 l_{\rm s2}^2 - l_{\rm s1}l_{\rm s2}\left[\left(\frac{dR_0}{dT_0}\right)l_{\rm s}^2 - 12A_{\rm s}\lambda_{\rm s}l_{\rm s}\left(\frac{dR}{dP_{\rm s}}\right)\right]}{A_{\rm s}\lambda_{\rm s}l_{\rm s}\left[\left(\frac{dR_0}{dT_0}\right)l_{\rm s}^2 - 12A_{\rm s}\lambda_{\rm s}l_{\rm s}\left(\frac{dR}{dP_{\rm s}}\right)\right]}$ (1)

where λ_{1D} and A_{1D} are the thermal conductivity and the cross-sectional area of the 1D sample, respectively; l_{1D} is the length of the 1D sample between the two connecting points at the heat sink and the nanofilm; dR_0/dT_0 is the slope of the resistance-temperature relationship of the Pt nanofilm; dR/dP_s is the slope of the relationship between the measured resistance of the Pt nanofilm (*R*) and Joule power (*P*_s) after the 1D sample transfer; A_s , λ_s and l_s are the cross-sectional area, the thermal conductivity, and the length of the nanofilm, respectively; l_{s1} and l_{s2} are the lengths of the nanofilm between the junction and the ends of the nanofilm, as depicted in Fig. 1.

We assembled the measurement circuit modules, the STEM detector, and other accessories in the SEM chamber, and utilized the STEM-in-SEM for the concurrent internal structure observation during the thermal conductivity measurement. The details of the experimental setup are provided in the Supplementary Materials. As illustrated in Fig. 1, the suspended nanofilm is deliberately fabricated on the edge of the silicon wafer so that the electron beam can transmit through the 1D sample and the internal structure can be imaged by the STEM detector. See Supplementary Note S1 for the fabrication procedures and SEM images of the suspended platinum nanofilm on the edge of the silicon wafer.

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as follows,^{9, 37}

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FIG. 1. Schematic illustration of the *in-situ* thermal conductivity measurement method using
STEM-in-SEM.

97 Using this experimental setup, we in-situ measured the thermal conductivity of two high-98 temperature treated cup-stacked CNTs, and concurrently observed the internal structures. See 99 Supplementary Note S2 and S3 for more details about how the samples were picked up and transferred 100 to the measurement devices. The cup-stacked CNT is a chain of truncated graphite cups stacked together, and the graphite cups are tilted a few degrees relative to the longitudinal axis.³⁶ Figure 2 shows the SEM 101 102 and STEM images of CNT-a and CNT-b, where the probe, CNT, and the edge of the silicon wafer can 103 be clearly distinguished. Figure 2(c) also presents the typical TEM micrograph of this kind of CNT, in 104 which the cupped wall can be identified. The TEM image was acquired on a TEM (JEM-2100Plus, 105 JEOL) with an electron accelerating voltage of 200 kV. However, the electron accelerating voltages here 106 for SEM and STEM observations were 10 kV and 30 kV, respectively. We have compared the STEM 107 images with different modes and found the high-angle annular dark field (HAADF) mode gives the best imaging performance, where the internal hollow structure of the cup-stacked CNT can be distinguished. 108 109 The STEM images in this paper are all in the HAADF mode. We measured the outer diameter (D_0) and 110 inner diameter (Di) of the CNTs from the STEM images. The outer and inner diameters can vary along

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111	the length and we measured the diameters at about 50 different locations. D_0 and D_i were measured to
112	be 103.0 \pm 4.3 nm and 32.9 \pm 4.5 nm for CNT-a, and 118.9 \pm 8.6 nm and 52.9 \pm 8.4 nm for CNT-b. The
113	image brightness of CNT-a is almost uniform in the SEM image in Fig. 2(a), but significantly changes
114	along the length in the STEM image in Fig. 2(b). The dark segment of CNT-a in Fig. 2(b) indicates that
115	the CNT was significantly bent after being transferred to the measurement device, so we had to measure
116	the length of CNT-a from the STEM image before the CNT transfer (Supplementary Fig. S3(a)). In
117	contrast, CNT-b has a uniform image brightness in the STEM image of Fig. 2(e), indicating that CNT-
118	b nearly lies in the same plane. We measured the CNT lengths between the probe and the nanofilm to
119	be 14.5 μm for CNT-a and 10.0 μm for CNT-b. In addition, we can see the white dot-like structural
120	defects or impurities in CNT-a. Thus, on the whole, we observed more structural disorders or non-
121	uniformity in CNT-a than in CNT-b, which can cause a lower thermal conductivity in CNT-a. Note that
122	in the previous SEM-based <i>in-situ</i> thermal measurements, ^{38, 39} it is impossible to <i>in-situ</i> measure the
123	inner diameter of the measured segment, not to mention the evaluation of the non-uniformity in the
124	internal structure. The visualization of the internal structure of 1D material during the <i>in-situ</i> thermal
125	conductivity measurement is a major achievement in this study.



FIG. 2. (a) SEM and (b) STEM images of CNT-a. (c) The typical TEM micrograph of the cupstacked CNT, which is on the same TEM grid with CNT-a. Inset: schematic illustration of the
cup-stacked CNT. (d) SEM and (e) STEM images of CNT-b.

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132 Figure 3 shows the *in-situ* thermal measurement results. Before the CNT transfer, we measured the resistance of the Pt sensor (R) as a function of the Joule power ($P_s = I_s V_s$, where I_s and V_s are the current 133 134 and voltage, respectively) at different environment temperatures (T_0). Note that the current in this paper 135 only refers to the direct current applied to the nanofilm. In this baseline measurement, we calibrated the 136 resistance-temperature relationship and the thermal conductivity of the Pt nanofilm. The inset of Fig. 137 3(a) shows the baseline measurement results of the Pt nanofilm used for CNT-a at 278.15 to 318.15 K. 138 By extrapolating the $R-P_s$ curve to zero heating power, we can get the sensor resistance at the 139 environment temperature. Further, from the $R-P_s$ slope, we can calculate the thermal conductivity of the

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140	nanofilm using $\lambda_s = (dR_0/dT_0)l_s/[12A_s(dR/dP_s)]^{.9, 34, 40}$ The suspended Pt nanofilms used for CNT-a and
141	CNT-b are 9.6 μm and 9.7 μm in length, 674.7 nm and 464.3 in width, and 40 nm in thickness. Fig. 3(a)
142	shows the temperature-dependent electrical resistance and thermal conductivity of the nanofilm used
143	for CNT-a. The electrical resistance changes linearly with temperature, and the slope dR_0/dT_0 was 0.213
144	±0.003 Ω/K. Figure 3(b) shows the change in the resistance of the nanofilm ($\Delta R = R - R_0$) as a function
145	of the Joule power in the baseline measurement and after CNT-a transfer. The corresponding results for
146	CNT-b are provided in Supplementary Fig. S4. The slope dR_0/dT_0 of the nanofilm used for CNT-b was
147	$0.289\pm0.003~\Omega/K$. To eliminate the heating effect of the electron beam, we turned off the electron beam
148	when we conducted the thermal conductivity measurement. Compared with the baseline measurement,
149	the change in the resistance of the nanofilm decreased after being bonded with the CNT samples, since
150	part of the heat flux went through the CNT to the heat sink (i.e. the tungsten probe) and the average
151	temperature rise of the nanofilm decreased. Based on the obtained dR_0/dT_0 , the average temperature rise
152	of the nanofilm (θ) was obtained as $\theta = \Delta R/(dR_0/dT_0)$. Figure 3(c) illustrates the difference in the average
153	temperature rise of the Pt nanofilm after the CNT transfer and baseline measurement ($\theta - \theta_{BL}$), which
154	clearly reveals the difference. Using Eq. (1), we measured the total thermal resistance for CNT-a and
155	CNT-b to be $(8.9 \pm 5.0) \times 10^7$ K/W and $(3.3 \pm 0.4) \times 10^7$ K/W, respectively. Although we cannot separate
156	the thermal contact resistance $(R_{t,c})$ in our measurement, $R_{t,c}$ is negligible as reported in the literature
157	with similar contact conditions, ^{8, 9, 34, 41} since we bonded the CNT firmly with the sensor and the heat
158	sink using EBID. Thus, we took $R_{t,c}$ in Eq. (1) as 0 and calculated the thermal conductivities which here
159	correspond to the lower bound of the actual thermal conductivities. Here we used the shell cross-
160	sectional area of the CNT for the thermal conductivity calculation, which is the same as the previous
161	measurements on cup-stacked CNTs. ^{41, 42} As shown in Fig. 3(c), the thermal conductivity of CNT-a and
162	CNT-b are 21.7 \pm 12.4 W/m·K and 33.8 \pm 8.0 W/m·K, respectively, which approximately fall in the
163	range of the reported thermal conductivity of this kind of cup-stacked CNT in previous measurements. ^{41,}
164	⁴² Our uncertainty analysis is provided in Supplementary Note S6. It should be pointed out that the



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previous measurements in Ref. 42 did not provide the uncertainty, while the uncertainty reported in Ref. 41 could be underestimated. The thermal conductivity of cup-stacked CNTs is dominated by the interfacial thermal resistance between graphene or graphite cups, which can be affected by structural bending and disorders. The thermal conductivity difference between CNT-a and CNT-b can be explained by the structural difference observed in the STEM images as discussed earlier, as well as the sample variation in the crystallization defect levels that cannot be observed with STEM-in-SEM.



FIG. 3. (a) The temperature dependence of the resistance at zero heating power, and the thermal
conductivity, of the Pt nanofilm before transferring CNT-a. Inset: the baseline measurement
results for the relationship between the resistance of the nanofilm and the Joule heating power.
(b) The change in the resistance of the nanofilm as a function of the Joule power in the baseline
measurement and after CNT-a transfer. (c) The difference in the average temperature rise of the
nanofilm after the CNT transfer and baseline measurement. (d) The thermal conductivities of

179	CNT-a and CNT-b plotted with the literature results.
180	
181	One concern about our method is whether the electron beam can damage the sample, since the
182	electron beam can introduce defects in graphene. ⁴³ Actually, for multi-walled nanotubes or nanowires,
183	the electron-beam-induced damage is negligible under TEM observation where the acceleration voltage
184	is normally 200 kV or 300 kV.36, 44, 45 In our work, the acceleration voltage of STEM-in-SEM
185	observation is 30 kV, which is much lower than TEM and ensures the sample safety. Besides, the data
186	was stable during the measurement, which also confirmed the negligible electron-beam effect. We also
187	evaluated the heating effect of the electron beam irradiation by monitoring the temperature change in
188	the Pt sensor. From Fig. S5, we found that the electron beam does heat the sample and the temperature
189	change caused by the EB irradiation is less than 0.6 K. To avoid the EB heating effect, we turned off the
190	EB when we conducted the thermal conductivity measurement of the CNTs, so the EB irradiation does
191	not affect the thermal conductivity results. In the future, because the movement of the silicon wafer and
192	the probe are independently controlled by the SEM stage and the manipulator, we can also introduce
193	deformation by moving the probe and study the effect of deformation on the properties.
194	In conclusion, we have developed an experimental method that enables concurrent thermal
195	conductivity measurement and internal structure observation of single 1D materials using STEM-in-
196	SEM. Utilizing this setup, we observed the internal non-uniform structures of the cup-stacked CNTs
197	and measured the thermal conductivity in situ. The thermal conductivity results fall in the range of the
198	previously reported values, while the thermal conductivity difference between our measured samples
199	can be attributed to the structural difference. Our experimental method can find wide applications in the
200	sample-by-sample elucidation of the structure-property correlation for 1D materials in real time.
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202	Supplementary Material
203	See supplementary material for further details on the fabrication procedures of the suspended
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platinum nanofilm on the edge of the silicon wafer, practical images of the experimental setup for the *in-situ* and real-time thermal characterization, thermal measurement results of CNT-b, the tests on the
effects of the electron beam irradiation and the current applied to the nanofilm sensor on thermal
characterization and the uncertainty analysis.

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- 214 Data Availability

The data that supports the findings of this study are available within the article and the supplementary material.

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